

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/684,519	10/10/2000	Jin-Yuan Lee	MEG2000-001	3369
28112	7590 10/02/2003		\ EXAMINER	
GEORGE O. SAILE & ASSOCIATES			BUI, HUNG S	
28 DAVIS A	VENUE PSIE, NY 12603		ART UNIT PAPER NUMBER	PAPER NUMBER
TOOGHIEDE	1512, 111 12005		2841	

DATE MAILED: 10/02/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

,			um
	Application No.	Applicant(s)	
	09/684,519	LEE, YIN-YUAN	
Office Action Summary	Examiner	Art Unit	
	Hung S Bui	2841	
The MAILING DATE of this communication app Period for Reply	ears on the c ver sheet v	vith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, may a within the statutory minimum of the fill apply and will expire SIX (6) MC cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communication BANDONED (35 U.S.C. § 133).	i.
1) Responsive to communication(s) filed on	<u>.</u> .		
2a) This action is FINAL . 2b) ⊠ Thi	is action is non-final.		
3) Since this application is in condition for allowa closed in accordance with the practice under I Disposition of Claims			S
4) Claim(s) <u>1-4,7-38,43-45,47,50-53,57-63,65,67</u>	and 68 is/are pending ir	the application.	
4a) Of the above claim(s) is/are withdraw	vn from consideration.		
5) Claim(s) is/are allowed.		·	
6) Claim(s) <u>1-4,7,8,18-25,28-38,52,53 and 57-59</u>	is/are rejected.		
7) Claim(s) <u>9-17, 26-27,43-45, 47, 50-51,60-63, 6</u>	5, 67 and 68 is/are object	ted to.	
8) Claim(s) are subject to restriction and/or	election requirement.		
Application Papers			
9)☐ The specification is objected to by the Examiner			
10)☐ The drawing(s) filed on is/are: a)☐ accep	ted or b) objected to by	the Examiner.	•
Applicant may not request that any objection to the			
11)☐ The proposed drawing correction filed on	is: a) ☐ approved b) ☐	disapproved by the Examiner.	
If approved, corrected drawings are required in rep	•	·	
12) The oath or declaration is objected to by the Exa	aminer.		
Priority under 35 U.S.C. §§ 119 and 120			
13) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
1. Certified copies of the priority documents	have been received.		
2. Certified copies of the priority documents	have been received in A	Application No	
 3. Copies of the certified copies of the priori application from the International Bur * See the attached detailed Office action for a list of 	eau (PCT Rule 17.2(a)).	•	
14) Acknowledgment is made of a claim for domestic	·		on).
a) ☐ The translation of the foreign language prov 15)☐ Acknowledgment is made of a claim for domestic	visional application has t	een received.	•
Attachment(s)	. ,		
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s)		Summary (PTO-413) Paper No(s) Informal Patent Application (PTO-152)	

Art Unit: 2841

DETAILED ACTION

1. The indicated allowability of claims 7-8, 25, 29-34, 46, 48-49, and 59 are withdrawn in view of the newly discovered reference(s) to Akram et al. [US 6,091,252]. Rejections based on the newly cited reference(s) follow.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-4, 8, 18-25, 28-34, 35-38, 53, 57-59 are rejected under 35 U.S.C. 103(a) as being unpatentable over Anderson et al. [US 5,969,461] in view of Lin et al. [US 5,450,283] and Akram et al. [US 6,091,252].

Regarding claims 35-38, Anderson et al. discloses a printed circuit board structure (figure 1) comprising:

- a circuit board substrate (16) on the surface of which at least one point of an electrical contact (18) has been provided;
- one or more layers of underfill material (28) applied to the surface of the printed circuit board;
- a device (10) having a plurality of solder balls (20) mounted thereon; and

Art Unit: 2841

wherein electrical contact is made between the point of electrical contact on the surface of the printed circuit board and at least one of the solder balls.

Anderson et al. disclose the instant claimed invention except for the specific material used for the underfill material and the device being a semiconductor device and depositing a layer of conductive material over the created layer of thermal relieve material and patterning the layer of conductive material.

Lin et al. disclose a semiconductor flip chip (18) mounted on a printed circuit board (12) via a plurality of solder balls (64) with an underfill layer (28) formed of a thermal stress reducing compliant material.

It would have been obvious to a person having ordinary skill in the art at the time invention was made to use the thermal stress reducing compliant material of Lin et al. for the underfill material of Anderson et al., for the purpose of reducing stress between the chip and the circuit board.

Akram et al. disclose using an electroplate process for depositing a layer of conductive material (28) over a created thermal stress relieve material (34) including an opening and patterning the conductive layer to form traces to interconnect contact pads (22, column 6, lines 6-51).

It would have been obvious to a person having ordinary skill in the art at the time invention was made to use the deposition process and patterning technique of Akram et al. in Anderson et al. in view of Lin et al., for the purpose of interconnecting components mounted on the substrate.

Art Unit: 2841

Regarding claim 53, Anderson et al. disclose curing the thermal stress relieve material (see abstract).

Regarding claims 57-59, Anderson et al. disclose the instant claimed invention except for the multiple layer printed circuit board structure and resin filler overlying points of electrical contact.

Lin et al. disclose a multiple layer printed circuit board structure and resin filler overlying points of electrical contact (14) mounted on an upper surface of the printed circuit board with interconnecting vias (figure 9).

It would have been obvious to a person having ordinary skill in the art at the time invention was made to use the multi layer circuit board/contact design of Lin et al. for the printed circuit board of Anderson et al., for the purpose of providing multiple signal paths and facilitating mounting of the semiconductor chip.

Regarding claims 1-4, 8, 18-25 and 28-34, as acknowledged by applicant (see response to restriction), the claimed method steps would have been inherent in the product structure.

4. Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Anderson et al. in view of Lin et al. and Akram et al. as applied to claim 1 above, and further in view of Numata et al. [US 4,792,476].

Regarding claim 7, Anderson et al. in view of Lin et al. and Akram et al. disclose the instant claimed invention except for the use of a photolithography process to create one or more openings in the created thermal stress relieve material layer.

Art Unit: 2841

Numata et al. disclose the use of a photolithography process to create one or more openings in a created thermal stress relieve material layer (column 1, lines 15-54).

It would have been obvious to a person having ordinary skill in the art at the time invention was made to use a photolithography process to create one or more openings in the created thermal stress relieve material layer of Anderson et al., as modified, as suggested by Numata et al., for the purpose of forming the openings on the thermal stress relieve layer.

5. Claim 52 is rejected under 35 U.S.C. 103(a) as being unpatentable over Anderson et al. in view of Lin et al. and Akram et al. as applied to claim 1 above, and further in view of Downes, Jr. et al. [US 6,373,717].

Anderson et al. in view of Lin et al. and Akram et al. disclose the instant claimed invention except for the surface of the thermal stress relieve material being roughened prior to application of the conductive deposition.

Downes, Jr. et al. disclose that it is known to roughen a stress relieve surface prior to the application of an conductive deposition.

It would have been obvious to a person having ordinary skill in the art at the time invention was made to roughen the surface of the thermal stress relieve layer of Anderson et al. in view of Lin et al. and Akram et al., as suggested by Downes, Jr. et al., for the purpose of improving adhesion of the deposition.

Art Unit: 2841

Allowable Subject Matter

6. Claims 9-17, 26-27, 43-45, 47, 50-51 and 60-68 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Response to Arguments

7. Applicant's arguments with respect to claims 1-4, 7-38, 43-45, 47, 50-53, 57-63, 65 and 67-68 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hung S Bui whose telephone number is (703) 305-8024. The examiner can normally be reached on Monday-Friday 8:30AM-6:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David S. Martin can be reached on (703) 308-3121. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 305-0956.

HB 9/13/03

> DAVID MARTIN SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800